

4" version 6" version

UV LED exposure-masking system

The UV-KUB 2 is a very compact exposure and masking system equipped with a LED based optical head, collimated and homogenous.

Controlled by touchscreen, the UV-KUB 2 ensures safety through an entirely closed exposure chamber, with both hard or soft contact modes available. Thanks to its hermetic configuration, this equipment doesn't need to be installed in a clean room.



Technological breakthroughs

High quality collimation

Divergence angle below 2° offers the possibility to work in masking mode on thick layers without altering the rendering of edges of the patterns.

This **high-quality collimation** allows to reach resolution down to the micrometre scale without needing a vacuum contact mode.

LED technology

Perfectly monochromatic exposure light source.

A cold UV source, prevents undesirable thermal effects.

Possibility to operate in continuous or pulse mode.

Long lifetime: the uv-led light source is no longer considered as a consumable item.

Related applications











Photonics Surface functionalization





UV LED exposure-masking system

Performances

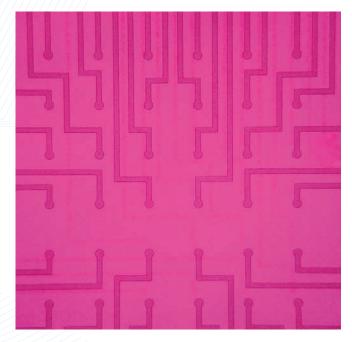
	Resolution	2μm
	Divergence angle	< 2°
	Number of programmable cycles	10
	Exposure cycles (continuous/discontinuous)	From 1s to 1h
	Processes	Hard (physical) or soft (proximity) contact processes

UV-LED source

Wav	velength	365nm +/- 5nm
Hon	nogeneous exposure	+/- 5%
Life	time of the LEDS	> 10 000 hours

Working/Writing surfaces

Working surface	4" or 6" wafers
Substrate warm-up during exposure	< 1°C
Compatible photoresist	SU8, Shipley, AZ Resist, K-CL resist (developed by Kloe)



Other features

- Size: 260(L) x 260(W) x 260(H)mm
- Weight: 8,2kg / 18lbs
- Colour touchscreen: 5,7" diagonal
- Power density: 35mW/cm² +/- 10%
- Power supply: 100V/240V 50Hz/60Hz
- Consumption: 180W
- Distance control between the mask and the wafer: 10µm
- Full plate exposure: 6mm
- Substrate thickness + layers: maximum 2mm



